

Docket No. 247866US2S



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF: Akira HOKAZONO, et al.

SERIAL NO: 10/759,205

GAU: 2811

RCE FILED: Herewith

EXAMINER: Magee, T.J.

FOR: SEMICONDUCTOR DEVICE HAVING METAL SILICIDE FILMS FORMED ON SOURCE AND DRAIN REGIONS AND METHOD FOR MANUFACTURING THE SAME

REQUEST FOR EXTENSION OF TIME
UNDER 37 C.F.R. 1.136

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

It is hereby requested that a **three** month extension of time be granted to December 29, 2005 for

- ☐ filing a response to the Official Action dated.
- ☐ responding to the requirements in the Notice of Allowability dated:
- ☐ filing the Formal Drawings. The Issue Fee due has been timely filed.
- ☐ responding to the Notice to File Missing Parts of Application dated:
- ☒ filing an RCE. A timely response to the final rejection, due September 29, 2005 is being filed herewith.
- ☐ filing an Appeal Brief. A Notice of Appeal was filed on:
- ☐ Applicant claims small entity status. See 37 CFR 1.27. Therefore, the fee amount shown below is reduced by one-half.

The required fee of \$1,020.00 is enclosed herewith by credit card payment and any further charges may be made against the Attorney of Record's Deposit Account No. 15-0030. A duplicate copy of this sheet is enclosed.

Respectfully Submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.

Eckhard H. Kuesters

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Limited Recognition No. L0037